Ternary Ta$_2$NiSe$_5$ Flakes for a High-Performance Infrared Photodetector

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Multielemental systems enable the use of multiple degrees of freedom for control of physical properties by means of stoichiometric variation. This has attracted extremely high interest in the field of 2D optoelectronics in recent years. Here, for the first time, multilayer 2D ternary Ta$_2$NiSe$_5$ flakes are successfully fabricated using a mechanical exfoliation method from chemical vapor transport synthesized high quality bulk and the optoelectronic properties are systematically investigated. Importantly, a high responsivity of 17.21 A W$^{-1}$ and high external quantum efficiency of 2645% are recorded from an as-fabricated photodetector at room temperature in air; this is superior to most other 2D materials-based photodetectors that have been reported. More intriguingly, a usual sublinear and an unusual superlinear light-intensity-dependent photocurrent are observed under air and vacuum, respectively. These excellent and special properties make multilayer ternary Ta$_2$NiSe$_5$ a highly competitive candidate for future infrared optoelectronic applications and an interesting platform for photophysics studies.

1. Introduction

Infrared (IR) photodetectors have wide applications in many fields including military communication, medical and environmental monitoring, remote control, and thermal imaging$^{[1-4]}$ and have attracted increasing attention in recent years. In the past decades, numerous IR photodetectors have been fabricated based on traditional narrow-bandgap materials, such as InAs, InSb, HgZnTe, and HgCdTe.$^{[5]}$ However, not to mention the toxicity of these materials, the bulk lattice structure of these semiconductors makes them difficult in monolithic integration and fabrication flexible devices applications in near future.$^{[6]}$

2D materials have layered structure, which renders them great advantages in the applications of monolithic integration, flexible devices, and even wearables.$^{[4,6,7]}$ Interestingly, the electron structure of 2D semiconductors is usually related to the number of layers and external strain, providing simple ways to tune the optoelectronic properties just by changing the number of layers or strain engineering.$^{[7]}$ Motivated by these, a large number of 2D materials such as graphene,$^{[8,9]}$ GeSe,$^{[10]}$ SnS$_2$,$^{[11]}$ MoS$_2$,$^{[12,13]}$ black phosphorus,$^{[4,14]}$ ReSe$_2$,$^{[15,16]}$ and MoS$_2$/black phosphorus heterojunction$^{[17]}$ have been attempted in IR photodetectors. However, only the very recently reported (3-aminopropyl) triethoxysilane (APTES) and triphenylphosphine (PPh$_3$) treated ReSe$_2$ IR detector exhibited a high performance with photoresponsivity of about 10$^4$ A W$^{-1}$ and switch time of about 50 ms.$^{[15]}$ Most IR photodetectors are still suffering from drawbacks such as low responsivity,$^{[8,9,14]}$ slow response,$^{[8,9]}$ and environmental instability.$^{[4,14,17]}$

Ternary Ta$_2$NiSe$_5$ is a layered material stacked by weak van der Waals interaction.$^{[18]}$ The structure can be characterized as a series of zigzag wave chains (Figure 1a), in which [TaSe$_6$]$_2$ dimer chains that composed by two [TaSe$_6$] octahedral single chains interconnect with NiSe$_4$ tetrahedral single chains, are periodically assembled.$^{[18,19]}$ This distorted chain structure makes a considerable anisotropic electrical behavior expected within the layer plane.$^{[20]}$ Especially, bulk Ta$_2$NiSe$_5$ is a direct banggap semiconductor ($E_g$ = 0.36 eV)$^{[20,21]}$ unlike most transition metal dichalcogenides (TMDs) undergone an indirect-to-direct bandgap transition when scaled down to monolayer.$^{[22]}$ Ta$_2$NiSe$_5$ will maintain its direct bandgap nature.$^{[23]}$ This unique robust electronic character makes Ta$_2$NiSe$_5$ an ideally candidate for those applications in which high carrier concentration and large light adsorption efficiency are simultaneously demanded. Moreover, Ta$_2$NiSe$_5$ will experience a second-order phase transition at a critical temperature of 328 K.$^{[24,25]}$ Below this temperature, anomalous flattening and broadening of the valence-band occur, which indicates the existing of excitonic insulator (EI) ground state.$^{[24]}$ The direct bandgap nature combined with the EI phase offers an unprecedented opportunity to directly study the effect of photoexcitation when electronic states implicated in the exciton formation.$^{[26]}$ As for 2D Ta$_2$NiSe$_5$ material fabrication, only the work of ultrathin flakes...
has been reported recently, in which Ta$_2$NiSe$_5$ nanosheets are acquired with high yield by liquid exfoliation method. However, the merit of high yield of liquid exfoliation method is degraded by the drawbacks by small size (typically several hundred nanometers in length) and low quality of products, which hinders the studies and applications of samples for electronics and optoelectronics. Considering the unique robust moderate direct bandgap of Ta$_2$NiSe$_5$, we speculate it will be a promising candidate for IR photodetectors of excellent responsivity. Compared to single elemental or binary systems, ternary systems have more degrees of freedom to tune the electronic or optoelectronic properties of systems just by means of stoichiometric variation.

Herein, multilayer ternary chalcogenide Ta$_2$NiSe$_5$ flakes are successfully exfoliated via mechanical exfoliation method from chemical vapor transport (CVT) synthesized single crystalline bulk; moreover, their optoelectronic properties have been systematically studied as well. An excellent IR photoresponsivity of 17.21 A W$^{-1}$ and high external quantum efficiency (EQE) of 2645% in air are collected from Ta$_2$NiSe$_5$ flakes-based IR photodetector, superior to most of other reported 2D materials-based IR photodetectors. More interestingly, a usual sublinear and an unusual superlinear light intensity dependence of photocurrent under air and vacuum have been observed, respectively, which could be attributed to the combined effect of adsorbents and different types of recombination centers in our samples. The excellent and special photoelectronic properties make Ta$_2$NiSe$_5$ a promising active 2D material for future application in optoelectronics and an interesting platform for photophysics study.

2. Results and Discussion

The 3D structural model of Ta$_2$NiSe$_5$ crystal shown in Figure 1a clearly stresses the layered nature and Van Der Waals interaction among single layers. In addition, the distance between adjacent layers is $\approx$0.66 nm. The top view of the Ta$_2$NiSe$_5$ crystal is shown in Figure 1b, and the synthesis details could be found in the Experimental Section. Figure 1c shows powder X-ray diffraction (XRD) pattern of Ta$_2$NiSe$_5$ crystal. All peaks can be indexed to the monoclinic space group C2/c (JCPDS PDF No. 01-078-0279).

Figure 1. Synthesis and characterization of Ta$_2$NiSe$_5$ single crystals. a) Structural model of layered Ta$_2$NiSe$_5$. b) Schematic diagram of CVT process. c) XRD pattern of layered Ta$_2$NiSe$_5$ crystal, inset: the optical image of Ta$_2$NiSe$_5$ single crystal. d) EDX result of Ta$_2$NiSe$_5$ single crystal. e) SEM image and EDS elemental mapping of an exfoliated Ta$_2$NiSe$_5$ microflake.
orientation along the [020] direction. The energy-dispersive X-ray spectroscopy (EDS) spectrum of a Ta₂NiSe₅ single crystal shown in Figure 1d gives strong signals of Ta, Ni, and Se, and agrees well with the stoichiometric of Ta₂NiSe₅. Figure 1e shows the scanning electron microscopy (SEM) image and EDS elemental mapping of an exfoliated Ta₂NiSe₅ microflake. These results reveal a layered structure and a uniform spatial distribution of Ta, Ni, and Se of our synthesized sample.

Moreover, the X-ray photoelectron spectroscopy (XPS) was also used to characterize Ta₂NiSe₅ crystal sample, as shown in Figure S2 (Supporting Information). The whole XPS spectrum of Ta₂NiSe₅ demonstrated in Figure S2a (Supporting Information) clearly identified the signals of elements of Ta, Ni, and Se. The fitted peaks located around 23.4 and 25.7 eV of Ta 4f spectrum shown in Figure S2b (Supporting Information) can be indexed to the core level peaks of Ta 4f⁷/₂ and Ta 4f⁵/₂.[24] Besides, the two fitted peaks at 853.8 and 861.7 eV of Ni 2p spectrum exhibited in Figure S2c (Supporting Information) represent the binding energies of Ni²⁺ in Ta₂NiSe₅.[19,24] While three peaks fitted at 53.3, 54.2, and 55.4 eV of Se 3d spectrum displayed in Figure S2d (Supporting Information) are ascribed to Se²⁻ of Ta₂NiSe₅.[19,24]

Compared with chemical vapor deposition or liquid exfoliation method, 2D flakes prepared by mechanical exfoliation always have clean surface, pristine state, and high-quality structures.[39] Here, through this scotch tape-based exfoliation method, we achieved multilayer Ta₂NiSe₅ flakes, details can be found in the Experimental Section. The optical microscope photograph of typical mechanical exfoliated Ta₂NiSe₅ flakes is shown in Figure 2a, from which one can see that the length of the dark section is up to 15 μm, much larger than the liquid exfoliated counterpart.[19] The corresponding atomic force microscopy (AFM) image in Figure 2b confirms the thickness is ≈7 nm (about ten layers). Figure 2c shows the low magnitude transmission electron microscopy (TEM) image of a typical mechanical exfoliated Ta₂NiSe₅ flake. The corresponding high-resolution TEM (HRTEM) image presented in Figure 2d exhibits a clear and sharp lattice fringe with an interplanar distance of 0.393 nm, corresponding to the (004) planes, further confirming the single-crystalline nature.

To determine the optoelectronic properties of multilayer Ta₂NiSe₅, photodetectors based on exfoliated Ta₂NiSe₅ flakes are fabricated using standard electron-beam lithography (EBL). Here, if not specially noted, the photoelectronic measurements were taken under excitation of 808 nm laser. Figure 3 summarizes the optoelectronic properties of a multilayer Ta₂NiSe₅ photodetector under air condition. The multilayer Ta₂NiSe₅-based 1R photodetector is schematically shown in Figure 3a, where Cr/Au top electrodes were patterned via thermal evaporation. Figure 3b exhibits the comparison of I–V relationship under dark condition and under laser illumination with different power intensities. The inset shows the AFM image of the device in which one can see that the thickness of Ta₂NiSe₅ flake is ≈9.4 nm and the separation between two Cr/Au electrodes is about 4.9 μm. Note that all I–V curves exhibit nearly linear behavior, indicating a good Ohmic contact between Ta₂NiSe₅ flake and Cr/Au electrodes. The slopes of the I–V curves increased with increasing power density, suggesting the power density-dependent photocurrent relationship. To further investigate this relationship, we measured the time-dependent photoresponse using different power densities range from 94 to 838 mV cm⁻¹, as shown in Figure 3c. Then, we can plot the dependent curve of photocurrent I ph (I ph = I illumination − I dark) versus incident laser intensity (P), as exhibited in Figure 3d, in which one can see that the I ph is proportional to Pβ with a fitting value β = 0.98. This value is less than 1, but very close to 1, showing a sublinear behavior. We also measured the wavelength dependent photocurrent spectrum for the photodetector (see Figure S3, Supporting Information), which clearly reveals a wide photoresponse range. The cyclability of the photodetector is checked under power intensity of 481 mW cm⁻¹ (V bias = 0.1 V) by artificially switching on/off the incident light at an interval of 20 s. Several cycles were performed and the result was shown in Figure 3e, from which one can achieved that there is little deviation during cycles, revealing the photoresponse of the detector is reversible and...
stable. Figure 3f described the magnified plot of one circle of Figure 3e, the rising time ($\tau_{\text{rising}}$) and decay time ($\tau_{\text{decay}}$) are 3.0 and 3.3 s, respectively. The switching speed is slower than APTES and PPh$_3$ treated ReSe$_2$ photodetector[15] but is comparable or faster than many other reported 2D IR detectors (e.g., about 10$^2$ for graphene nanoribbons, monolayer graphene and bilayer MoS$_2$).[8,9,12] Future improvement of switch time might be obtained by O$_2$ plasma treatment according to the literature.[40] The persistent photoconductivity as in Figure 3f is well known to produce due to charge trap[41] and could be eliminated by making photo thin-film transistor using gate pulse voltage after illumination stopped.[42–44]

Besides response rate, the responsivity ($R_{\lambda}$) and EQE are other two crucial parameters to evaluate the sensitivity of photodetectors.[2,7,45–48] Responsivity can be defined as, $R_{\lambda} = I_{\text{ph}}/PS$, where $I_{\text{ph}}$ is the photogenerated current, $P$ is the power intensity of the laser, and $S$ is the effective irradiated area of the flake. In our study, the $S$ is 5.58 $\mu$m$^2$ and $I_{\text{ph}}$ is 0.46 $\mu$A under power intensity of 481 mW cm$^{-2}$ at $V_{\text{bias}} = 0.1$ V, thus, the calculated responsivity is 17.21 A W$^{-1}$. Such a value is about two orders of magnitude higher than monolayer graphene and few layers black phosphorus.[9,14] Afterward, the EQE can be calculated according to $\text{EQE} = hcR_{\lambda}/e\lambda$, where $h$, $c$, $\lambda$, and $e$ are the Plank’s constant, velocity of light, exciting wavelength, and elementary electronic charge, respectively. The calculated value of EQE is 2645%. The values of photoresponsivity and EQE of our device are superior to many other reported 2D-based IR detectors as summarized in Table 1, suggesting that Ta$_2$NiSe$_5$ flakes are promising in the applications of infrared photodetection. The photoelectronic properties were also performance on two other different thicknesses flakes, and are shown in Figure S4 (Supporting Information). The thicker device exhibits a much higher photocurrent and higher responsivity, which can be contributed to the relatively weaker scattering and higher light
Table 1. Comparison in the performance of IR photodetectors based on multilayer Ta2NiSe5 and some previously reported 2D materials.

<table>
<thead>
<tr>
<th>Materials</th>
<th>Wavelength [nm]</th>
<th>External bias [V]</th>
<th>Rs [A W⁻¹]</th>
<th>EQE [%]</th>
<th>Switching time [s]</th>
<th>Reference</th>
</tr>
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<tr>
<td>Graphene nanoribbons</td>
<td>1550</td>
<td>2</td>
<td>1</td>
<td>80</td>
<td>≈10¹</td>
<td>[8]</td>
</tr>
<tr>
<td>Monolayer graphene</td>
<td>1470</td>
<td>0.02</td>
<td>0.2</td>
<td>–</td>
<td>–</td>
<td>[9]</td>
</tr>
<tr>
<td>Few layers black phosphorus</td>
<td>≈1550</td>
<td>2</td>
<td>0.657</td>
<td>–</td>
<td>–</td>
<td>[14]</td>
</tr>
<tr>
<td>GeSe nanosheet</td>
<td>808</td>
<td>4</td>
<td>≈3.5</td>
<td>530</td>
<td>0.1</td>
<td>[10]</td>
</tr>
<tr>
<td>SnS2 nanosheets</td>
<td>850</td>
<td>5</td>
<td>9.2×10⁻⁴</td>
<td>0.15</td>
<td>–</td>
<td>[11]</td>
</tr>
<tr>
<td>Bilayer MoSe₂</td>
<td>1070</td>
<td>0.8</td>
<td>5.2</td>
<td>–</td>
<td>≈10¹</td>
<td>[12]</td>
</tr>
<tr>
<td>Multilayer MoS₂</td>
<td>850</td>
<td>1</td>
<td>9×10⁻⁵</td>
<td>–</td>
<td>–</td>
<td>[13]</td>
</tr>
<tr>
<td>Multilayer Ta₂NiSe₅</td>
<td>808</td>
<td>0.1</td>
<td>17.21</td>
<td>2645</td>
<td>τₘₙᵢₜᵢᵢ = 3.0, τₑᵡᵩᵢᵢ = 3.3</td>
<td>This work</td>
</tr>
</tbody>
</table>

absorbability.[⁴⁰] Thus, the thickness control is very important for future applications.

In order to investigate the photoconductive mechanism, the photoelectric measurements of the device were also performed under vacuum (≈10⁻⁴ Torr) condition. Figure 4a,b shows the I–V characteristics of the photodetector under dark and laser illumination in different atmospheres, respectively. One can see that both the dark current and illumination current in vacuum are higher than that in air (see Figure 3e, Iₖ = 4.41 μA and Iᵣ = 4.87 μA). As shown in Figure 4d, the response rate in vacuum is 34.3 and 33.3 s for rising and decay, respectively, which are much slower than that obtained in air (see Figure 3f, τᵣᵣᵢᵢᵢᵢ = 3.0 s and τₑᵡᵩᵢᵢᵢᵢ = 3.3 s). In short, the photocurrent in vacuum is larger than that in ambient while the response rate in vacuum is much slower. This phenomenon supports the well-accepted effect of oxygen chemisorption on the photosensitivity.[⁴⁸–⁵²] Field effect transistor measurement described in Figure S5 (Supporting Information) confirmed the Ta₂NiSe₅ is n-type, suggesting the conductivity depends mainly on electrons. In air condition, oxygen molecules adsorbed onto the surface of the multilayer Ta₂NiSe₅, captured free electrons from the flake, in agreement with the scheme [O₂(g) + e⁻ → O₂⁻ (ad)], which creates a depletion layer near the surface, resulting in low conductivity in the dark state.[⁴⁹,⁵₀,⁵²] When exposed to laser with energy larger than the band gap, electron–hole pairs are generated, and the holes migrate to the surface and combine with O₂⁻ through [h⁺ + O₂⁻ (ad) → O₂ (g)], resulting in an increment of electron concentration, which further lead to the photocurrent enhancement.[¹⁰,⁴⁹,⁵²] When in vacuum, the electrons of negatively O₂⁻ return to the depletion layer on the flake surface, leading to increase of the carrier lifetime.[⁴⁸] So the current is higher in vacuum than that in air. In addition, the longer carrier lifetime makes a longer recombination time, causing a slower response rate in vacuum. Figure 4e shows the light intensity-dependent photoresponse under vacuum condition. As expected, the photocurrent increase with increasing power density. More importantly, the saturation platform of photocurrent is growing even steeper with increasing power density, which means it may take more time for achieving photocurrent saturation under higher intensity, such interesting phenomenon will be discussed below. Figure 4f illustrates the intensity dependent photocurrent under vacuum, two points should be noted: one is that the exponent β in air (β = 0.98) is smaller than that under vacuum (β = 1.1); the other is that the exponent β is larger than 1, showing a superlinear behavior. The first phenomenon is normal which reflects that the recombination probability of photoexcited carriers could be increased due to the existing of adsorbates in air, causing the fall in responsivity.[⁵³] However, the later one is unusual, which will be discussed below.

The most interesting finding which has not well explained is summarized here: the fitting exponent β of intensity dependence of photocurrent in air is less than 1, showing a sublinear behavior; while in vacuum, the value of β is larger than 1, exhibiting a superlinear behavior. We assume that both hole-trapping on the surface due to the oxygen adsorption and desorption and the existence of different types of recombination centers which will be discussed below contribute to the above-mentioned phenomenon. In vacuum, the adsorbents are lack, the presence of different recombination centers contribute to the superlinear phenomenon.[³⁴,³⁵] To explain the superlinear behavior of Ta₂NiSe₅ in vacuum, we present a model as described in Figure 5. For simplicity, three types of recombination centers (RCs, the existence of in-gap states due to selenium vacancy or defect may act as recombination centers[⁹,⁵⁶–⁵⁸]) with different energies and capture cross-sections are presented. RC₁, RC₂, and RC₃ are located near the valence, mid- and conduction band, respectively, here, RC₁ have a low electron capture cross-section but a high hole capture cross-section but a high hole capture cross-section, while RC₂ and RC₃ have both large holes and electrons capture cross-sections. Under dark, the Fermi level (Eᶠ) is located above RC₁ and RC₂, but below RC₃. When illuminated by light, the hole and electron concentrations are augmented, leading the Quasi-Fermi levels Eᶠ⁺ and Eᶠ⁻ move apart. At low intensity, the RC₁ and RC₂ are mostly occupied, while the RC₃ are mostly empty, and the recombination rate is dominated by RC₃. With increasing the power density, the occupancy ratio of RC₁ and RC₂ decrease, while occupancy ratio of RC₃ increase. When the intensity is high enough, the density of empty RC₁, RC₂, and RC₃ are comparable, resulting in the huge drops of recombination rate, further leading to the superlinear. The existence of different types of recombination centers have also been used to explain the
superlinear behavior in MoS$_{2(1-x)}$Se$_x$. Moreover, the steeper and steeper saturation platform of photocurrent with increasing power density shown in Figure 4e indicate the recombination rate drops with intensity, confirming our deduction. Such superlinear behavior also has been observed in graphene and MoS$_2$ photodetectors. When in air, the adsorbents contribution is increased. At higher intensities, the number of available hole-traps present at the surface is dramatically reduced, leading to the sublinear behavior. In short, the adsorbents and different types of recombination centers should take responsibility for the sublinear and superlinear of light intensity-dependent photocurrent, respectively. In air, the impact from the adsorbents is larger than recombination centers, leading to sublinear; while in vacuum, the contribution from recombination centers is greater, causing superlinear behavior.

To understand in depth the photoelectronic performance of multilayer Ta$_2$NiSe$_5$, we further investigated the electrotransport and photocurrent at various temperatures. Here, all measurements are performed under vacuum of $\approx 10^{-4}$ Torr. Figure 6a shows the typical $I$–$V$ curves of the Ta$_2$NiSe$_5$ device at various temperature, it can be seen that all the curves exhibit nearly linear behavior, suggesting good Ohmic contact at all temperatures. The temperature dependence resistance of the device is shown in Figure 6b, as can be seen, the resistance decreases with increasing temperature, showing a typical semiconductor behavior, similar to the literature. Furthermore, the activation energy calculated from the fitting curves of ln$R$ versus $1/T$ is 257 meV, which fits the narrow band-gap nature of Ta$_2$NiSe$_5$. Figure 6c shows the normalized time-resolved photoresponse at various temperatures, from which one can obviously obtained that the photoresponse of the detector dependent strongly on the temperature, that is, the photoresponse decrease as the temperature increase. The in-gap states which have discussed above may be responsible for this phenomenon. More detailed,
the recombination speed of captured electrons in the in-gap states will be faster with the increase of temperature, therefore, the photoresponse reduced.\(^9\) As described in Figure 6d, the on/off ratio continuously increases from 1.85 to 62.22 as the temperature decrease from 300 to 20 K. The increase of on/off ratio can be explained by the strongly suppressed of dark current at low temperature as is shown in Figure 6d.\(^59\)

3. Conclusion

We for the first time have successfully isolated high quality multilayer flakes of ternary Ta\(_2\)NiSe\(_5\) from corresponding bulk crystal via mechanical exfoliation technique from CVT synthesized single crystalline bulk and fabricated IR photo detectors based on as-isolated samples. A high responsivity of 17.21 A W\(^{-1}\) and outstanding EQE of 2645% at room temperature in air condition are collected, which is superior to most of reported other 2D materials-based photodetectors. In addition, we observed a normal sublinear and an abnormal superlinear illumination intensity dependence of photocurrent under air and vacuum, respectively. We assume that the combined effect of adsorbents and different types of recombination centers should take responsibility for such interesting phenomenon. Moreover, low temperature study reveal that the photoresponse of IR photodetectors decrease with temperature increase. Our finding not

Figure 5. Schematic to explain the behavior of superlinear photocurrent. Bandgap model with three different types of recombination centers (RCs) under dark (left image), low (centered image), and high (right image) power density illuminated conditions. \(E_F\) is the Fermi level, \(E_{Fn}\) and \(E_{Fp}\) are the quasi Fermi levels of electrons and holes under illumination, respectively.

Figure 6. a) I–V curves of the device at different temperatures in vacuum. b) Temperature dependence resistance of multilayer Ta\(_2\)NiSe\(_5\), inset: \(\ln R\) as the function of 1000/\(T\). c) Normalized time-resolved photoresponse at various temperatures recorded for a power density of 481 mW cm\(^{-1}\). d) On/off ratio and \(I_{dark}\) at different temperatures.
only suggests that layered \( \text{Ta}_2\text{NiSe}_5 \) is a very promising ternary material for the development of 2D optoelectronic device, but also provide a platform to explore novel photophysics regarding the unusual superlinear behavior.

4. Experimental Section

Synthesis of \( \text{Ta}_2\text{NiSe}_5 \): Single Crystals: High-quality \( \text{Ta}_2\text{NiSe}_5 \) single crystals were prepared by the CVT method using iodine as a transport agent in a horizontal two-zone furnace. 1 g starting materials of high-purity Ta, Ni, and Se powders (≥99.9%, Alfa) were mixed stoichiometrically and ground thoroughly, then vacuum sealed (≥10⁻⁴ Torr) into a quartz tube with some additional iodine (10 mg cm⁻¹). The tube was slowly heated up to 850 °C on one end while the other end was kept at 800 °C. After 10 d of growth, shiny crystals with strip-like shape were obtained, with typical dimensions of 10 × 3 × 0.2 mm².

Mechanical Exfoliation: Multilayer \( \text{Ta}_2\text{NiSe}_5 \) flakes were isolated from the corresponding bulk crystals and then transferred onto the freshly cleaned Si wafer containing a 300 nm thick SiO₂ dielectric layer. An optical microscope (Olympus, BX51) equipped with a charge-coupled device (Olympus, DP73) was used to examine the flakes. The thickness of the \( \text{Ta}_2\text{NiSe}_5 \) flakes was first roughly evaluated from different interference color using the optical microscope and then precisely determined by AFM.

Characterization: The XRD patterns were collected with a Rigaku-TR3 X-ray diffractometer using Cu-Kα radiation at room temperature in the 2θ range of 10°–70° with a scan step width of 0.02°. The composition and elements distribution of as-fabricated microflake was determined by energy dispersive X-ray spectroscopy (EDX) attached to the SEM (FEI Helios Nanolab 600i). XPS was performed on a Thermo Fisher VG ESCALAB 250 instrument using Al Kα as X-ray source. The transmission electron microscopy (TEM) and HRTEM was applied on JEM-2100(HR) to investigate the microstructure of the exfoliated samples. The thickness measurements of the exfoliated flakes were carried out with AFM (SPM9700).

Device Fabrication and Measurements: The photodetector devices were fabricated by standard EBL and deposited Cr/Au (10 nm/40 nm) as contact electrodes using thermal evaporation (Nexdep, Angstrom Engineering). An 808 nm laser with tunable electrodes using thermal evaporation (Nexdep, Angstrom Engineering). Fabricated by standard EBL and deposited Cr/Au (10 nm/40 nm) as contact AFM (SPM9700).

Supporting Information

Supporting Information is available from the Wiley Online Library or from the author.

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